

In The Specification

Between paragraphs [0014] and [0015], please insert the following paragraph:

FIG. 4c illustrates graphically the illumination pattern of the illumination strip.

Delete paragraph [0016].

In paragraph [0027] insert the following text:

The purpose of Filter A as shown in FIG 4c is to provide the pattern of the illumination strip. The illumination strip is the actual EUV light that the EUVL mask is scanned across. Depending on the exposure system design, the pattern in this filter may or may not need the capability to move with the EUVL reticle and/or EUV illumination strip. The width and speed of this complimentary illumination pattern can be control variables. A liquid crystal filter would be adequate for this purpose.